## X-RAY SCIENCE DIVISION

## 431/D030 Facility Hazard Analysis

The purpose of this form is to serve as a summary of facility characteristics, recognized hazards, implemented hazard controls, pertinent sources of information, and incident reporting contacts.

Scope of work conducted in this facility: Vacuum parts cleaning and etching of sapphire crystals Hazardous materials/equipment associated with this facility: Oven Glove Box Laser **Organic Solvents** Acids Hazards associated with this facility: **Corrosive Materials** Thermal Surfaces Flammable Liquids Hazard controls implemented within this facility: **Engineered Controls Procedural Controls PPE** Fume Hood Sapphire Crystal Etching Safety Glasses/goggles Chemical Resistant Glove/Apron/Sleeve Glove Box Laser Eyewash and Safety Shower Satellite Waste Accumulation Face shield **GFCI Outlets** Temperature Resistant Gloves Relevant ESH manual chapters that may be associated with this facility: 1) Ch. 4.1 Hazard Communication 2) Ch. 4.3 Laboratory and Chemical Safety 3) Ch. 6.2 Laser Safety Pertinent safety training courses that may be associated with this facility: 1) ESH115 Laboratory Hazard Communication 2) ESH195 Personnel Protective Equipment 3) ESH574 Chemical Waste Generator Note: This is not intended to be an all-inclusive list of training that is required to work within this facility. The authoritative record of required training is depicted by the individual's JHQ. **Incident reporting contacts:** \*\*\*\*Dial 911 in an emergency\*\*\*\* Lab Safety Captain: Jiyong Zhao Extension: 9195 Group Leader: Thomas Gog Extension: 0320 **ES&H** Coordinator: Paul Rossi Extension: 4192 Facility hazard analysis completed by: Lab Safety Captain or designee Date Reviewed and approved by: **ES&H** Coordinator Date Line Management Date

This hazard analysis must be reviewed and updated accordingly on an annual basis or whenever conditions change. Once approved, this hazard analysis must then be posted in a conspicuous space within the facility.